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Electronic Version v1.1

Stylesheet Version v1.1.0

Title of Invention	METHOD FOR IMAGE REVERSAL OF IMPLANT RESIST USING A SINGLE PHOTOLITHOGRAPHY EXPOSURE AND STRUCTURES FORMED THEREBY
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Application Number :

Date :

First Named Applicant: Steven J. Holmes

Confirmation Number:

Attorney Docket Number: FIS920030151US2

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Submitted By:	Elec. Sign.	Sign. Capacity
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Documents being submitted:	Files
us-fee-sheet	epave-usfees.xml us-fee-sheet.xsl us-fee-sheet.dtd
us-ids	epave-usidst.xml us-ids.dtd us-ids.xsl
us-request	epave-usrequ.xml us-request.dtd us-request.xsl
application-body	specification-trans.xml us-application-body.xsl application-body.dtd wipo.ent mathml2.dtd mathml2-qname-1.mod isoamsa.ent isoamsb.ent isoamsc.ent isoamsn.ent isoamso.ent isoamsr.ent isogrk3.ent isomfrk.ent isomopf.ent isomscr.ent isotech.ent isobox.ent isocyr1.ent isocyr2.ent isodia.ent isolat1.ent isolat2.ent isonum.ent isopub.ent mmlextra.ent mmlalias.ent soextblk.dtd figures1abcd.tif figures1efgh.tif figures2abcd.tif figures2e3ab.tif declarationp1.tif declarationp2.tif declarationp3.tif declarationp4.tif declarationp5.tif
us-declaration	
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